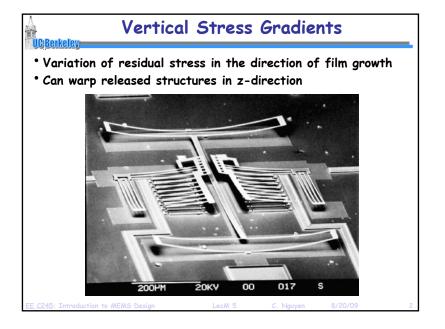


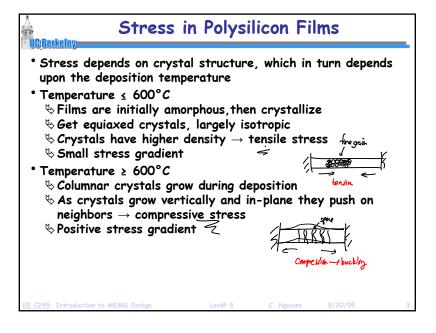
Prof. Clark T.-C. Nguyen

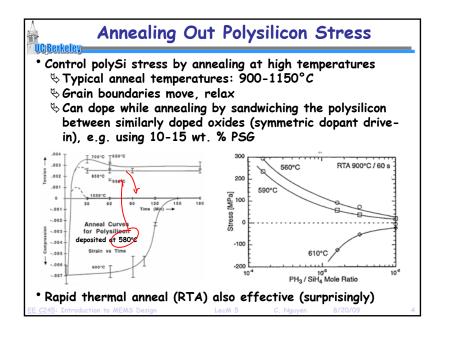
Dept. of Electrical Engineering & Computer Sciences University of California at Berkeley Berkeley, CA 94720

Lecture Module 5: Surface Micromachining

EE C245: Introduction to MEMS Design LecM 5 C. Nauyen 8/20/09







Topography Issues

\* Degradation of lithographic resolution pose problems for PR step coverage, streaking

Thickness differences pose problems for reduction steppers

